# SMALL-ANGLE SCATTERING SHORT COURSE 2010 "BEYOND R<sub>G</sub>"

## MARCH 27-31, 2010

#### **ADVANCED PHOTON SOURCE, ARGONNE NATIONAL LABORATORY**

http://small-angle.aps.anl.gov

This course will provide a better understanding of smallangle scattering (SAXS) theory and the techniques used at the Advanced Photon Source (APS) at Argonne National Laboratory, together with hands-on experience.

Participants are expected to be at the post-doctoral or higher level, with their own defined experimental programs and samples to use during the course.

Highlights include:

- Overview of SAXS theory, capabilities, and use
- Description of various data reduction and analysis tools
- Hands-on experience with data collection on participants' own samples
- Supervised data reduction and analysis
- Instruction on creation of effective proposals to obtain APS general-user beam time

The course will begin with an optional two days of data collection at APS beamlines, followed by three days of morning lectures and afternoon data reduction and analysis. During both data collection and analysis, lecturers will be available for one-on-one discussions.

A CD (Windows systems) with several types of data reduction and analysis software will be provided to each student for use during and after the workshop.

Participants should bring their own notebook computers.

SEE OTHER SIDE FOR COURSE INFORMATION Registration fee: \$0 (free) Number of participants is limited to 25. If needed, organizers reserve the right to select participants. Registration details: http://small-angle.aps.anl.gov Registration opens: November 1, 2009 Registration deadline: December 20, 2009 Information about acceptance of registration will be sent to participants before January 15, 2010 Participants will be responsible for their own transportation, accommodations, and meal costs. A limited number of rooms has been set aside at the **Argonne Guest House** Guest House Web site: http://www.anlgh.org/ Guest House phone: 800.632.8990 or 630.739.6000 Guest House fax: 630.739.1000 Guest House email: argonne-guest-house@anl.gov Participants are responsible for making their own reservations.

#### FOR ANSWERS TO QUESTIONS OR FOR MORE INFORMATION CONTACT

SUSAN STRASSER STRASSER@APS.ANL.GOV OR APSUSER@APS.ANL.GOV APS USER OFFICE Argonne National Laboratory 9700 S. Cass Ave., Bldg. 401 Argonne, IL U.S.A. APS on the Web: www.aps.anl.gov

#### **COURSE SCHEDULE**

March 27-28: Experiments (optional) March 29-31: Lectures, data reduction, and modeling

#### **SYLLABUS**

- Small-Angle Scattering Fundamentals
- Sample Preparation and Experiments
- Overview of Available Instrumentation and Techniques
- Data Reduction Tools
- Data Analysis Tools
- Scientific Lectures on SAS in Materials Science, Chemistry, Biology, and Polymer Science
- Strategies to Write Successful Beam-Time Proposals

#### **SPEAKERS**

Dale Schaefer (University of Cincinnati) David Tiede (Argonne) Randall E. Winans (Argonne) Byeongdu Lee (Argonne) Jan Ilavsky (Argonne) Peter R. Jemian (Argonne)

### **PARTICIPATING BEAMLINES**

Bonse-Hart Ultra-SAXS:32-ID (XOR, http://usaxs.xor.aps.anl.gov)Pinhole SAXS:5-ID (DND-CAT, http://www.dnd.aps.anl.gov/)12-ID (XOR/BESSRC, http://cep.xor.aps.anl.gov/)18-ID (Bio-CAT, http://www.bio.aps.anl.gov/)Details on the beamlines: http://small-angle.aps.anl.gov/aps\_beam\_lines.html

#### **EXPERIMENTAL TECHNIQUES**

Ultra-SAXS (32-ID), Materials science SAXS, Bio-SAXS

#### SOFTWARE

"Irena" and "Nika" (http://usaxs.xor.aps.anl.gov/staff/ilavsky/irena.html, http://usaxs.xor.aps.anl.gov/staff/ilavsky/nika.html)

NIST SAS package (http://www.nenr.nist.gov/programs/sans/data/red\_anal.html) ATSAS (http://www.embl-hamburg.de/ExternalInfo/Research/Sax/software.html)

#### ILLUSTRATIONS

Background: Ultra-SAXS data from monosized distribution of silica spheres, courtesy of Jan Ilavsky (Argonne)

Top image: Small-angle scattering from aerogel as a function of axial or radial strain, courtesy of Johannes Pollanen (Northwestern University) Middle image: Speckle pattern from coherent beam scattering of an aerogel,

courtesy of Lawrence Lurio (Northern Illinois University)

Bottom image: Key polyethylene crystalline and lamellae deformation mechanisms, courtesy of Brian Landes (The Dow Chemical Company)

